### Analysis of Laser-Imprinting Reduction in Spherical-RT Experiments with Si-/Ge-Doped Plastic Targets



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#### Summary

# A few percent of Si-/Ge-doping into plastic ablators can reduce the $\sigma_{\rm rms}$ of shell- $\rho R$ perturbations by a factor of 3 to 5



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- Experimental results show
  - a factor of 2 to 3 reduction in the laser imprinting efficiency
  - reduced RT growth rate by ~50% when high-Z-doped targets are used
- The experimental observations are reproduced by radiation-hydrodynamics simulations using 2-D DRACO



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### Hydro-simulations predicted that high-Z doping can mitigate laser-imprinting effects\* on target implosions

- High-Z doping can increase the standoff distance between the ablation surface and the laser-deposition regions, thereby reducing the imprint
- Radiation preheat from high-Z doping increase the ablation velocity, leading to enhanced ablative stabilization of the RT growth
- Implosions with Si-/Ge-doped plastic targets\*\* have shown a yield increase by a factor of >2, which have been attributed to improved target stability
- Thin-layer (<1000 Å) high-Z coatings\*\*\* have also shown yield improvements in target implosions

- \*\* V. N. Goncharov et al., Phys. Plasmas, <u>15</u>, 056310 (2008);
  - J. P. Knauer et al., Bull. Am. Phys. Soc. 52, 233 (2007);
  - P. B. Radha et al., Bull. Am. Phys. Soc. <u>52</u>, 143 (2007).
- \*\*\* S. P. Obenschain et al., Phys. Plasmas <u>9</u>, 2234 (2002);

<sup>\*</sup> S. X. Hu *et al.*, "Mitigating Laser Imprints in Direct-Drive ICF Implosions with High-Z Dopants," submitted to Physical Review Letters.

A. N. Mostovych et al., Phys. Rev. Lett. <u>100</u>, 075002 (2008).

#### LILAC simulations for pure-CH targets and 7.4% Si-doped CH targets indicate the expected laser-imprinting reduction effects



# Spherical-RT experiments with high-Z-doped targets (entire shell doping) were performed on OMEGA using the cone-in-shell configuration\*



## 2-D DRACO simulations predict ~3× lower laser imprinting amplitude for the CHSi [7.4%] target



## Both simulations and experiments show significant improvements of shell integrity with high-Z doping



## Significant imprinting reduction in $\rho R$ modulation by 3 to 5 times has been observed for high-Z-doped targets

Using the directly measured mass-absorption coefficients  $(\mu)$  of undriven targets, we can infer the evolution of  $\rho R$  modulations because of  $\Delta_{OD} = \mu \Delta_{\rho R}$ .



#### Summary/Conclusions

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NIF ignition designs using a CH ablator with halfway Si doping show no reduction in gain (radiation preheat effects minimized).